

Physical Constants

(in units frequently used in semiconductor electronics)

Electronic charge	q	$1.602 \times 10^{-19} \text{ C}$
Speed of light in vacuum	c	$2.998 \times 10^{10} \text{ cm s}^{-1}$
Permittivity of vacuum	ϵ_0	$8.854 \times 10^{-14} \text{ F cm}^{-1}$
Free electron mass	m_0	$9.11 \times 10^{-31} \text{ kg}$
Planck's constant	h	$6.626 \times 10^{-34} \text{ J s}$ $4.135 \times 10^{-15} \text{ eV s}$
Boltzmann's constant	k	$1.38 \times 10^{-23} \text{ J K}^{-1}$ $8.62 \times 10^{-5} \text{ eV K}^{-1}$
Avogadro's number	A_0	$6.022 \times 10^{23} \text{ molecules (g mole)}^{-1}$
Thermal voltage	$V_t = kT/q$	
at 80.6° F (300K)		2.586 mV
68° F (293K)		2.025 mV

Conversion Factors

$1 \text{ \AA} = 10^{-8} \text{ cm} = 0.1 \text{ nm}$
 $1 \text{ mil} = 10^{-3} \text{ inch} = 25.4 \text{ }\mu\text{m}$
 $1 \text{ eV} = 1.602 \times 10^{-19} \text{ J}$
 $1 \text{ J} = 10^7 \text{ erg}$

Appendix III

Properties of Semiconductor Materials

		E_g (ev)	μ_n ($\text{cm}^2/\text{V-s}$)	μ_p ($\text{cm}^2/\text{V-s}$)	m_{n}^*/m_0 (m_l, m_t)	m_{p}^*/m_0 (m_{lh}, m_{hh})	a (Å)	ϵ_r	Density (g/cm^3)	Melting point (°C)
Si	(i/D)	1.11	1350	480	0.98, 0.19	0.16, 0.49	5.43	11.8	2.33	1415
Ge	(i/D)	0.67	3900	1900	1.64, 0.082	0.04, 0.28	5.65	16	5.32	936
SiC (α)	(i/W)	2.86	500	—	0.6	1.0	3.08	10.2	3.21	2830
AlP	(i/Z)	2.45	80	—	—	0.2, 0.63	5.46	9.8	2.40	2000
AlAs	(i/Z)	2.16	1200	420	2.0	0.15, 0.76	5.66	10.9	3.60	1740
AlSb	(i/Z)	1.6	200	300	0.12	0.98	6.14	11	4.26	1080
GaP	(i/Z)	2.26	300	150	1.12, 0.22	0.14, 0.79	5.45	11.1	4.13	1467
GaAs	(d/Z)	1.43	8500	400	0.067	0.074, 0.50	5.65	13.2	5.31	1238
GaN	(d/Z, W)	3.4	380	—	0.19	0.60	4.5	12.2	6.1	2530
GaSb	(d/Z)	0.7	5000	1000	0.042	0.06, 0.23	6.09	15.7	5.61	712
InP	(d/Z)	1.35	4000	100	0.077	0.089, 0.85	5.87	12.4	4.79	1070
InAs	(d/Z)	0.36	22600	200	0.023	0.025, 0.41	6.06	14.6	5.67	943
InSb	(d/Z)	0.18	10^5	1700	0.014	0.015, 0.40	6.48	17.7	5.78	525
ZnS	(d/Z, W)	3.6	180	10	0.28	—	5.409	8.9	4.09	1650
ZnSe	(d/Z)	2.7	600	28	0.14	0.60	5.671	9.2	5.65	1100
ZnTe	(d/Z)	2.25	530	100	0.18	0.65	6.101	10.4	5.51	1238
CdS	(d/W, Z)	2.42	250	15	0.21	0.80	4.137	8.9	4.82	1475
CdSe	(d/W)	1.73	800	—	0.13	0.45	4.30	10.2	5.81	1258
CdTe	(d/Z)	1.58	1050	100	0.10	0.37	6.482	10.2	6.20	1098
PbS	(i/H)	0.37	575	200	0.22	0.29	5.936	17.0	7.6	1119
PbSe	(i/H)	0.27	1500	1500	—	—	6.147	23.6	8.73	1081
PbTe	(i/H)	0.29	6000	4000	0.17	0.20	6.452	30	8.16	925

All values at 300 K.

*Vaporizes

The first column lists the semiconductor, the second indicates band structure type and crystal structure. Definitions of symbols: *i* is indirect; *d* is direct; *D* is diamond; *Z* is zincblende; *W* is wurtzite; *H* is halite (NaCl). Values of mobility are for material of high purity.

Crystals in the wurtzite structure are not described completely by the single lattice constant given here, since the unit cell is not cubic. Several II-VI compounds can be grown in either the zincblende or wurtzite structures.

Many values quoted here are approximate or uncertain, particularly for the II-VI and IV-VI compounds. The gaps indicate that the values are unknown.

For electrons, the first set of band curvature effective masses is the longitudinal mass, the second set the transverse. For holes, the first set is for light holes, the second for heavy holes.

Useful Equations

Electron Momentum: $\mathbf{p} = m\mathbf{v} = \hbar\mathbf{k} = \frac{h}{\lambda}$ Planck: $E = h\nu = \hbar\omega$

Kinetic: $E = \frac{1}{2}mv^2 = \frac{1}{2}\frac{p^2}{m} = \frac{\hbar^2}{2m^*}\mathbf{k}^2$ (3-4) Effective mass: $m^* = \frac{\hbar^2}{d^2E/d\mathbf{k}^2}$ (3-3)

Total electron energy = P.E. + K.E. = $E_c + E(\mathbf{k})$

Fermi-Dirac e^- distribution: $f(E) = \frac{1}{e^{(E-E_F)/kT} + 1} \cong e^{(E_F-E)/kT}$ for $E \gg E_F$ (3-10)

Equilibrium: $n_0 = \int_{E_c}^{\infty} f(E)N(E)dE = N_c f(E_c) = N_c e^{-(E_c-E_F)/kT}$ (3-15)

$N_c = 2\left(\frac{2\pi m_n^* kT}{h^2}\right)^{3/2}$ $N_v = 2\left(\frac{2\pi m_p^* kT}{h^2}\right)^{3/2}$ (3-16), (3-20)

$p_0 = N_v[1 - f(E_v)] = N_v e^{-(E_F-E_v)/kT}$ (3-19)

$n_i = N_c e^{-(E_c-E_i)/kT}$, $p_i = N_v e^{-(E_i-E_v)/kT}$ (3-21)

$n_i = \sqrt{N_c N_v} e^{-E_g/2kT} = 2\left(\frac{2\pi kT}{h^2}\right)^{3/2} (m_n^* m_p^*)^{3/4} e^{-E_g/2kT}$ (3-23), (3-26)

Equilibrium: $n_0 = n_i e^{(E_F-E_i)/kT}$ $n_0 p_0 = n_i^2$ (3-25) (3-24)

Steady state: $n = N_c e^{-(E_c-F_n)/kT} = n_i e^{(F_n-E_i)/kT}$ $np = n_i^2 e^{(F_n-F_p)/kT}$ (4-15) (5-38)

$\mathcal{E}(x) = -\frac{d\mathcal{V}(x)}{dx} = \frac{1}{q} \frac{dE_i}{dx}$ (4-26)

Poisson: $\frac{d^2\mathcal{E}(x)}{dx^2} = -\frac{d^2\mathcal{V}(x)}{dx^2} = \frac{\rho(x)}{\epsilon} = \frac{q}{\epsilon}(p - n + N_d^+ - N_a^-)$ (5-14)

$\mu \equiv \frac{q\bar{v}}{m^*}$ (3-40a) Drift: $v_d \equiv \frac{\mu\mathcal{E}}{1 + \mu\mathcal{E}/v_s} \begin{cases} = \mu\mathcal{E} \text{ (low fields, ohmic)} \\ = v_s \text{ (high fields, saturated vel.)} \end{cases}$ (Fig. 6-9)

Drift current density: $\frac{I_x}{A} = J_x = q(n\mu_n + p\mu_p)\mathcal{E}_x = \sigma\mathcal{E}_x$ (3-43)

$$J_n(x) = q\mu_n n(x)\mathcal{E}(x) + qD_n \frac{dn(x)}{dx}$$

Conduction Current: drift diffusion (4-23)

$$J_p(x) = q\mu_p p(x)\mathcal{E}(x) - qD_p \frac{dp(x)}{dx}$$

$$J_{\text{total}} = J_{\text{conduction}} + J_{\text{displacement}} = J_n + J_p + C \frac{dV}{dt}$$

$$\text{Continuity: } \frac{\partial p(x, t)}{\partial t} = \frac{\partial \delta p}{\partial t} = -\frac{1}{q} \frac{\partial J_p}{\partial x} - \frac{\delta p}{\tau_p} \quad \frac{\partial \delta n}{\partial t} = \frac{1}{q} \frac{\partial J_n}{\partial x} - \frac{\delta n}{\tau_n} \quad (4-31)$$

$$\text{For steady state diffusion: } \frac{d^2 \delta n}{dx^2} = \frac{\delta n}{D_n \tau_n} \equiv \frac{\delta n}{L_n^2} \quad \frac{d^2 \delta p}{dx^2} = \frac{\delta p}{L_p^2} \quad (4-34)$$

$$\text{Diffusion length: } L \equiv \sqrt{D\tau} \quad \text{Einstein relation: } \frac{D}{\mu} = \frac{kT}{q} \quad (4-29)$$